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FLUORINATION OF METHIONINE AND METHIONYLGLYCINE DERIVATIVES
WITH XENON DIFLUORIDE*

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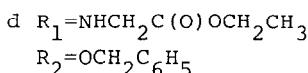
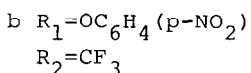
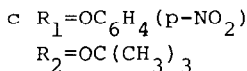
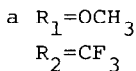
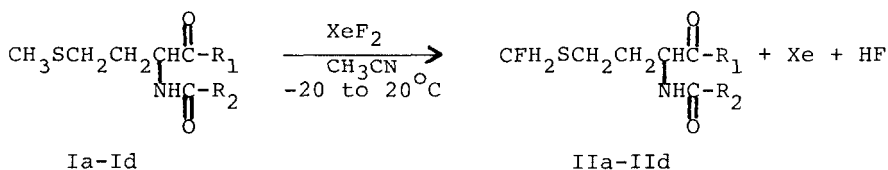
SUMMARY

A mild procedure for the fluorination of methionine and methionylglycine derivatives is described. Fluorination with xenon difluoride occurs at -20 to 20°C within 20-30 minutes in 70-90% yield, exclusively at the methylthio position. The products were characterized by elemental analysis, fluorine, proton and carbon NMR spectroscopy.

RESULTS AND DISCUSSION

The selective introduction of fluorine-19 or fluorine-18 labels into organic and biomolecules as probes for mechanistic and metabolic studies is still somewhat limited by the availability of effective fluorinating agents. The finding that XeF₂ is suitable for the α-fluorination of sulfides [1,2], combined with the recent preparation of fluorine-18 XeF₂ [3], suggests that XeF₂ might be useful for the labelling of other alkylthio derivatives and we wish to report a convenient method of fluorination of methionine and methionylglycine derivatives.

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Fluorination with xenon difluoride produces the fluoro-methionine (IIa-IIc) and fluoromethionylglycine (IIId) derivatives, as well as xenon gas and hydrogen fluoride. In a typical reaction, N-carbobenzoxy-L-methionylglycine ethyl ester (Id) (0.43 mmol) in acetonitrile (1 mL) in a syringe was injected onto a solution of xenon difluoride (0.45 mmol) in acetonitrile (0.5 mL) in a Teflon bottle with a rubber cap at -20°C . Xenon gas evolved on warming the sample to room temperature and the reaction, as conveniently monitored by the rise of the syringe plunger, was complete within 20-30 min. At the completion of the reaction, HF was destroyed by the addition of $(\text{Me}_3\text{Si})_2\text{NH}$ [4] (Safety note: Although no violent reactions were encountered in this work, the technique of destroying excess HF with $(\text{Me}_3\text{Si})_2\text{NH}$ is potentially hazardous because XeF_2 reacts explosively with some silicon-nitrogen compounds [5]). Removal of volatile material under vacuum left behind a solid which was recrystallized from benzene and petroleum ether, washed with cold toluene and dried under vacuum to give a white solid, identified as IIId, mp $99\text{-}100^\circ\text{C}$. Analysis [6]: Found: C, 52.82; H, 6.03; N, 7.22%. $\text{C}_{17}\text{H}_{23}\text{FO}_5\text{N}_2\text{S}$ requires C, 52.83; H, 6.00; N, 7.25%. A similar procedure was used for the preparation of compounds IIa-IIc.

The NMR spectral properties of the CFH_2S - group in IIa-IIId are very similar to those of the CFH_2S - group in simple mono-fluoroalkyl sulfides [2]. For the CFH_2S - group, δ_{H} 5.2-5.3 ppm (IIa-IIId), δ_{F} -184 ppm (IIId), $^2J_{\text{HF}}$ 52.4-53.1 Hz (IIa-IIId),

$^4J_{\text{FH}}$ 2.4 Hz (IIc), δ_{C} 88.9 ppm (IIId), and $^1J_{\text{CF}}$ 209.6 Hz (IIId). NMR examination showed that products IIa-IId were formed in yields of 70-90%, but no evidence was found for the formation of products with $\text{CF}_2\text{HS-}$ or $\text{CH}_3\text{SCFH-}$ substituents.

The stability of IIa-IId was briefly investigated and, in general, the thermal stability appeared comparable to that of the non-fluorinated starting compounds. A recrystallized sample of IIId was kept in a sealed tube at 0°C for 3 months without sign of decomposition. Under aqueous NaOH or Et_3N conditions, the $\text{CFH}_2\text{S-}$ group remained intact, as judged by NMR, but aqueous or non-aqueous solutions of HF, HCl or CF_3COOH produced decomposition with loss of the fluoride signal in the NMR spectrum.

ACKNOWLEDGEMENT

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